

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S85	5	"700946".ap.	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/10 19:39
S86	1	"10580606"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/10 20:04
S88	2	inert and S87	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/10 20:05
S87	7	(US-20040166240-\$ or US-20040253777-\$ or US-20050267253-\$ or US-20060151884-\$ or US-20040137243-\$ or US-20040166692-\$).did. or (US-6772710-\$).did.	US-PGPUB; USPAT	OR	ON	2009/06/10 20:05
S90	2	"2002205468"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/06/10 20:07
S89	0	"2002205468"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/10 20:07
S91	200	257/e21.262.ccls. and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/10 20:09
S92	59	inert adj gas and 257/e21.262.ccls. and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/10 20:10
S93	6	"580606".ap.	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/10 20:14
S94	0	oxidizer and inert adj gas and 257/e21.262.ccls. and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/10 20:34
S95	31	oxidiz\$3 and inert adj gas and 257/e21.262.ccls. and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/10 20:35
S96	2	("6772710").URPN.	USPAT	OR	ON	2009/06/10 20:48
S98	1	siloxane adj gas same oxid\$5 same carrier and porous	USPAT	OR	ON	2009/06/10 20:49
S97	48538	siloxane aj gas same oxid\$5 same carrier and porous	USPAT	OR	ON	2009/06/10 20:49
S100	38	cyclic organic (silica or silane or siloxane) same oxid\$5 same carrier and porous	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2009/06/10 20:50
S99	2	cyclic organic (silica or silane or siloxane) same oxid\$5 same carrier and porous	USPAT	SAME	ON	2009/06/10 20:50
S102	4	organic (silica or silane or siloxane) same oxid\$5 same carrier and porous and low-k	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2009/06/10 20:51

S101	1313	organic (silica or silane or siloxane) same oxid\$5 same carrier and porous	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2009/06/10 20:51
S103	74	(silica or silane or siloxane) same oxid\$5 same carrier and porous and low-k	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2009/06/10 20:52
S105	23	(siloxane) same oxid\$5 same carrier and low-k	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2009/06/10 21:00
S104	5	(siloxane) same oxid\$5 same carrier and porous and low-k	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2009/06/10 21:00
S106	266	(siloxane) same oxid\$5 same carrier and hydrocarbon	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2009/06/10 21:02
S107	7	(siloxane) same oxid\$5 same carrier and hydrocarbon and low-k	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2009/06/10 21:03
S108	104	tetraethylcyclotetrasiloxane	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/11 15:46
S110	14	inductive capacity same low-k	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2009/06/11 16:23
S109	1148	inductive capacity	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2009/06/11 16:23
S111	27	inductive capacity and low-k	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2009/06/11 16:24
S112	28	tetravinyltetramethylcyclotetrasiloxane and (inert or carrier)adj gas	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2009/06/11 17:02
S113	31	(tetravinyltetramethylcyclotetrasiloxane or tvtmcts)and (inert or carrier)adj gas	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2009/06/11 17:03
S117	0	(tetravinyltetramethylcyclotetrasiloxane or tvtmcts)and Si C O H	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2009/06/11 17:10
S116	0	(tetravinyltetramethylcyclotetrasiloxane or tvtmcts)and SiCO	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2009/06/11 17:10
S115	0	(tetravinyltetramethylcyclotetrasiloxane or tvtmcts)and SiCOH	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2009/06/11 17:10

S114	0	(tetra vinyl/tetra methyl cyclotetra siloxane or tvtmcts) and SiOOCH	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2009/06/11 17:10
S119	0	(tetra vinyl/tetra methyl cyclotetra siloxane or tvtmcts) SiC	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2009/06/11 17:11
S118	231	(tetra vinyl/tetra methyl cyclotetra siloxane or tvtmcts)	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2009/06/11 17:11
S120	6	"580606".ap.	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/11 17:58
S121	0	activat\$3 near gas same cyclic same siloxane	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/11 18:19
S123	14	(plasma or activat\$3 or excit\$5) near gas with ("CH.sub.4" or H or Ar or Xe or Kr) and cyclic same siloxane	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/11 18:20
S122	181	(plasma or activat\$3 or excit\$5) near gas and cyclic same siloxane	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/11 18:20
S125	8	(plasma or activat\$3 or excit\$5) near gas with ("CH.sub.4" or H or Ar or Xe or Kr) and cyclic same siloxane and (carrier or inert)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/06/11 18:22
S124	8	(plasma or activat\$3 or excit\$5) near gas with ("CH.sub.4" or H or Ar or Xe or Kr) and cyclic same siloxane and (carrier or inert)	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/11 18:22
S127	52	(rare or noble) near gas with ("CH.sub.4" or H or Ar or Xe or Kr) and cyclic same siloxane and (carrier or inert)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/06/11 18:24
S126	57	(plasma or activat\$3 or excit\$5 or rare or noble) near gas with ("CH.sub.4" or H or Ar or Xe or Kr) and cyclic same siloxane and (carrier or inert)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/06/11 18:24
S128	11	(rare) near gas with ("CH.sub.4" or H or Ar or Xe or Kr) and cyclic same siloxane and (carrier or inert)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/06/11 18:27
S129	22	("CH.sub.4" or H or Ar or Xe or Kr) near plasma and cyclic same siloxane and (carrier or inert)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/06/11 18:28
S130	149	("CH.sub.4" or H or Ar or Xe or Kr) adj plasma and siloxane and (carrier or inert)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/06/11 18:33
S132	20	plasma and S131	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/11 18:39

S131	20	(US-20040166240-\$ or US-20040253777-\$ or US-20050267253-\$ or US-20060151884-\$ or US-20040137243-\$ or US-20040166692-\$ or US-20020192980-\$ or US-20030139062-\$ or US-20020098714-\$ or US-20050276930-\$ or US-20050059258-\$ or US-20010031563-\$).did. or (US-6772710-\$ or US-7153580-\$ or US-6936537-\$ or US-7288292-\$ or US-6511903-\$ or US-6756323-\$ or US-6709715-\$ or US-6107184-\$).did.	US-PGPUB; USPAT	OR	ON	2009/06/11 18:39
S133	1	"20070093078"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/12 15:04
S135	3	pore with diameter peak and siloxane and dielectric near constant "2."?	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 16:00
S134	102	pore with diameter peak and siloxane	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 16:00
S136	6	("20030232495" "20040175957" "20040175958" "6420441" "6558747" "6737365").PN. OR ("7094681").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2009/06/12 16:22
S137	12	pore with diameter siloxane and dielectric near constant "2."?	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 16:32
S138	12	(nanopore or pore)with diameter siloxane and dielectric near constant "2."?	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 16:33
S139	27	("20020020327" "20020098279" "20020155053" "20030064321" "20030091838" "20030104225" "4634509" "5494859" "5693422" "5707783" "6022812" "6037275" "6197913" "6313045" "6359096" "6376634" "6391999" "6410150" "6413647" "6495479" "6512071" "6533855" "6534025" "6596404" "6632489" "6639015" "6696538").PN. OR ("7239018").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2009/06/12 16:35
S140	617	(nanopore or pore)with diameter and dielectric near constant "2."?	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:21
S142	128	(nanopore or pore)with diameter and cycl\$2 and dielectric near constant "2."? and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:22
S141	321	(nanopore or pore)with diameter and dielectric near constant "2."? and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:22
S143	9	(nanopore or pore or voids)with diameter "1" near nm and cycl\$2 and dielectric near constant "2."? and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:23
S144	1	"20070093078"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/12 18:26
S146	2	(nanopore or pore or voids)with diameter "0.4" nm and cycl\$2 and dielectric near constant "2."? and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:29
S145	65	(nanopore or pore or voids)with diameter nm and cycl\$2 and dielectric near constant "2."? and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:29
S148	12	(nanopore or pore or voids)with diameter "0.6" nm and cycl\$2 and dielectric near constant "2."? and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:30
S147	6	(nanopore or pore or voids)with diameter "0.5" nm and cycl\$2 and dielectric near constant "2."? and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:30

S151	0	(nanopore or pore or voids)with diameter "0.?" nm and cycl\$2 and dielectric near constant "2.?" and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:32
S150	7	(nanopore or pore or voids)with diameter "0.8" nm and cycl\$2 and dielectric near constant "2.?" and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:32
S149	0	(nanopore or pore or voids)with diameter "0.7" nm and cycl\$2 and dielectric near constant "2.?" and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:32
S153	2	(nanopore or pore or voids)with diameter "0.1" nm and cycl\$2 and dielectric near constant "2.?" and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:33
S152	0	(nanopore or pore or voids)with diameter "0.9" nm and cycl\$2 and dielectric near constant "2.?" and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:33
S155	8	(nanopore or pore or voids)with diameter "0.3" nm and cycl\$2 and dielectric near constant "2.?" and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:34
S154	1	(nanopore or pore or voids)with diameter "0.2" nm and cycl\$2 and dielectric near constant "2.?" and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	SAME	ON	2009/06/12 18:34
S156	6	"580606".ap.	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/20 13:34
S157	810	(porous or porosity or pores)same (dielectric near constant or specific adj inductive adj capacity)same ("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7") and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/20 14:11
S158	562	(porous or porosity or pores)same (dielectric near constant or specific adj inductive adj capacity)near6 ("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7") and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/20 14:12
S159	130	pore with distribution and (porous or porosity or pores) same (dielectric near constant or specific adj inductive adj capacity)near6 ("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7") and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/20 14:14
S164	21	pore with distribution and (porous or porosity or pores) same (dielectric near constant or specific adj inductive adj capacity)near6 ("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7") C near Si and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 14:24
S163	0	pore with distribution and (porous or porosity or pores) same (dielectric near constant or specific adj inductive adj capacity)near6 ("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7") C/Si and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 14:24
S162	0	pore with distribution and (porous or porosity or pores) same (dielectric near constant or specific adj inductive adj capacity)near6 ("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7") C/Si and O/Si and H/Si and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 14:24
S161	0	pore with distribution and (porous or porosity or pores) same (dielectric near constant or specific adj inductive adj capacity)near6 ("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7") C/Si and O/Si and H/Si and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	AND	ON	2009/06/20 14:24
S160	239	pore with distribution and (porous or porosity or pores) same (dielectric near constant or specific adj inductive adj capacity)near6 ("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7") C/Si and O/Si and H/Si and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS	OR	ON	2009/06/20 14:24

L2	11	methyilsilsesquioxane (formula or structure)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2009/06/20 16:28
L1	1244	methyilsilsesquioxane	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 16:28
L4	0	methyilsilsesquioxane same three member ring	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2009/06/20 16:30
L3	0	methyilsilsesquioxane (formula or structure) same three member ring	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2009/06/20 16:30
L7	5	(nano-porous or porous)(interlayer or insulat\$3 or dielectric) and three membered ring	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2009/06/20 16:31
L6	0	(nano-porous or porous)(interlayer or insulat\$3 or dielectric) and three member ring	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2009/06/20 16:31
L5	0	(nano-porous or porous)(interlayer or insulat\$3 or dielectric) same three member ring	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2009/06/20 16:31
L9	0	MSQ same three membered ring	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2009/06/20 16:36
L8	5	(nano-porous or porous or pore)(interlayer or insulat\$3 or dielectric) and three membered ring	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2009/06/20 16:36
L12	2	three membered silica	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2009/06/20 16:37
L11	0	MSQ same three membered silica	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2009/06/20 16:37

L10	4	MSQ same membered ring	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	NEAR	ON	2009/06/20 16:37
L13	0	cyclosiloxane (nano-porous or nanoporous or porous or pore or voids) (interlayer or dielectric or insulat\$3) dielectric near constant with("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2009/06/20 16:40
L17	547	cyclic siloxane (nano-porous or nanoporous or porous or pore or voids) (interlayer or dielectric or insulat\$3) dielectric near constant with("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 16:41
L16	0	cyclic siloxane (nano-porous or nanoporous or porous or pore or voids) (interlayer or dielectric or insulat\$3) dielectric near constant with("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 16:41
L15	0	cyclic siloxane (nano-porous or nanoporous or porous or pore or voids) (interlayer or dielectric or insulat\$3) dielectric near constant with("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 16:41
L14	0	cyclic siloxane (nano-porous or nanoporous or porous or pore or voids) (interlayer or dielectric or insulat\$3) dielectric near constant with("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	SAME	ON	2009/06/20 16:41
L18	287	cyclic siloxane (nano-porous or nanoporous or porous or pore or voids) (interlayer or dielectric or insulat\$3) dielectric near constant with("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7")and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 16:42
L20	9	cyclic siloxane (nano-porous or nanoporous or porous or pore or voids) (interlayer or dielectric or insulat\$3) dielectric near constant with("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7")and pore adj distribution and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 16:43
L19	131	cyclic siloxane (nano-porous or nanoporous or porous or pore or voids) (interlayer or dielectric or insulat\$3) dielectric near constant with("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7")and distribution and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 16:43
L21	9	(cyclic siloxane or cyclosiloxane)(nano-porous or nanoporous or porous or pore or voids) (interlayer or dielectric or insulat\$3) dielectric near constant with ("2.1" or "2.2" or "2.3" or "2.4" or "2.5" or "2.6" or "2.7")and pore adj distribution and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 16:48
L22	55	(cyclic siloxane or cyclosiloxane)(nano-porous or nanoporous or porous or pore or voids) and pore adj distribution and @ad<"20031128"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2009/06/20 16:50

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